

L Number	Hits	Search Text	DB	Time stamp
1	2	("5962184").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 09:39
2	6	(("5962184") or ("6150069") or ("6653047")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 09:39
24	2	("6303266").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 09:50
25	2	cylcoolefin same (norbornene styrene hydroxystyrene)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 09:57
51	2	(hexafluorocyclobutene octafluorocyclobutene) and (hydroxystyrene \$5hydroxystyrene norbornene)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:01
52	3	jp-2001330955-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:06
53	806	norbornene same (improve enhance increase)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:08
54	158	(norbornene same (improve enhance increase)) and (photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:08
55	116	((norbornene same (improve enhance increase)) and (photoresist resist)) and (\$5acid adj generator)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 11:00
56	6	("3418302" "3449304" "5637663" "5663255" "6133389" "6156824").PN.	USPAT	2004/04/05 10:10
57	2	("6111041").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:14
58	1	6111041.URPN.	USPAT	2004/04/05 10:15
59	1	"6034259".PN.	USPAT	2004/04/05 10:16
60	4	((("6593440") or ("6300440"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:17
61	8	((("20020004569") or ("6403846") or ("6261676") or ("4609715"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 11:00
50	141	hexafluorocyclobutene octafluorocyclobutene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/05 10:00
-	257	octafluoroclopentene hexafluorocyclobutene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/23 12:51
-	17	decafluorocyclohexene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 10:52
-	260	(octafluoroclopentene hexafluorocyclobutene) decafluorocyclohexene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:31

	30	((octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) and (photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2004/03/31 20:29
	2586	\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:08
	412107	(photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:08
	16849	(photoacid acid) near generat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:09
	1027638	solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:09
	10	(\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:16
	6	(US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.	USPAT; US-PGPUB	2003/09/22 11:10
	7	(((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:10
	3	(((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:29
	244	LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:23
	2	(LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO) and (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) (octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene)	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2004/03/31 20:29
	109	cycloolefin same (fluoro fluorinated fluorine)	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:43
	32	(perfluoro near ring)	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:56
	2	jp-2001122928-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT USPAT;	2003/09/22 11:50
	4	("6403744") or ("20030157432").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:49

	1	wo-200290423-\$ did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:49
	8	jp-2001330955-\$ did. jp-2001122928-\$ did. ((("6403744") or ("20030157432")). PN.) wo-200290423-\$ did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:50
	6	("3418302" "3449304" "5637663" "5663255" "6133389" "6156824"). PN.	USPAT	2003/09/22 11:53
	141	(cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:56
	9	((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 11:56
	9	((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:07
	1	poly adj octafluorocyclopent?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:08
	1	poly adj hexafluorocyclobut?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:09
	1	poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:10
	5368	cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
	3626	((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:12
	66	(cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
	65	((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (((((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19

	65	((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not ((((cycloolefin same (fluoro fluorinated fluorine)) (perfluoro near ring)) and ((photoresist resist)) and (photoacid acid) near generat\$4)) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) (US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO)) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:32
	1609	cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
	10	(cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
	10	((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not ((((cycloolefin same (fluoro fluorinated fluorine)) (perfluoro near ring)) and ((photoresist resist)) and (photoacid acid) near generat\$4)) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) (US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 12:19
	10	((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:32

-	7	((("5547558") or ("4566755") or ("4732941") or ("4500694") or ("4742140") or ("4609715") or ("4569871")).PN. jp-2001330955-\$.did.	USPAT	2003/09/22 14:13
-	2		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/22 15:04
-	35	((octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) and (photoresist resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:29
-	2	(LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO) and (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) (octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:29
-	3	(((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$) .did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$) .did.))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:30
-	485	octafluorocyclopent?ne hexafluorocyclobut?ne decafluorocyclohex?ne	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:32
-	11	((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")) .PN.) wo-200290423-\$.did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:32
-	82	((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not ((((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$) .did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$) .did.) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$) .did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$) .did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO)) not (jp-2001330955-\$.did. - jp-2001122928-\$.did. (((("6403744") or ("20030157432")) .PN.) wo-200290423-\$.did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:43
-	11000	\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:34

	51	((((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not ((((cycloolefin same (fluoro fluorinated fluorine)) (perfluoro near ring))) and ((photoresist resist)) and (((photoacid acid) near generat\$4)) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) (US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and (((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO)) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate) (octafluorocyclopent?ne hexafluorocyclobut?ne decafluorocyclohex?ne) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate) (US-6403846-\$ or US-6312759-\$ or US-6261676-\$ or US-6403744-\$).did. or (US-20030003379-\$ or US-20030008231-\$ or US-20030022101-\$ or US-20030152864-\$ or US-20020128336-\$ or US-20030157432-\$ or US-20020004569-\$ or US-20030157801-\$).did. or (WO-200290423-\$).did. (US-3449304-\$).did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:35
	4		USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:35
	13		USPAT; US-PGPUB; DERWENT	2004/03/31 21:07
	1		USOCR	2004/03/31 20:43

	95	<p>((octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) and (photoresist resist)) ((LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO) and (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) (octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene)) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and ((photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not (((((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring)) and (photoresist resist)) and (photoacid acid) near generat\$4) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne))) (US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and (photoresist resist)) and (photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO)) not ((jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.)) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:44
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	93	(((((octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) and (photoresist resist)) ((LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO) and ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) (octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene)) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.))) (((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.)) (((((cyclo\$4ene same (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (((((cycloolefin same (fluoro fluorinated fluorine)) ((perfluoro near ring)) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) (US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO))) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")).PN.) wo-200290423-\$.did.)) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate))) not ((octafluorocyclopent?ne hexafluorocyclobut?ne decafluorocyclohex?ne) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate)) (((("5962184") or ("6150069") or ("6653047")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 20:44
	3		USPAT	2004/03/31 21:00

	88	<p>(((((octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene) and (photoresist resist)) ((LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO) and (((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) (octafluorocyclopentene hexafluorocyclobutene) decafluorocyclohexene)) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.))) (((cyclo\$4ene near9 (fluoro fluorinated fluorine halogenated halogen chloro chlorinated chlorine bromine brominated bromo iodine iodinated iodo)) and (((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent)) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")) .PN.) wo-200290423-\$.did.))) (((((cyclo\$4ene same (fluoro fluorinated fluorine)) ((perfluoro near ring))) and ((photoresist resist)) and ((photoacid acid) near generat\$4)) and solvent) ((poly adj octafluorocyclopent?ne) (poly adj hexafluorocyclobut?ne)) ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) ((((\$6fluorocyclo\$3tene \$6fluorocyclo\$3tane) and ((photoresist resist)) and ((photoacid acid) near generat\$4) and solvent) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$).did. or (US-20030022101-\$ or US-20030008231-\$ or US-20030003379-\$).did.)) (LEE-GEUN-SOO LEE-GEUN-SU JUNG-JAE-CHANG JUNG-JAE-CHEUN SHIN-KI-S SHIN-KI-SOO))) not (jp-2001330955-\$.did. jp-2001122928-\$.did. (((("6403744") or ("20030157432")) .PN.) wo-200290423-\$.did.)) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate))) not ((octafluorocyclopent?ne hexafluorocyclobut?ne decafluorocyclohex?ne) and (\$6adamantyl \$6tricyclodecanyl 5-norbornene-2-carboxylate))) not ((US-6403846-\$ or US-6312759-\$ or US-6261676-\$ or US-6403744-\$).did. or (US-20030003379-\$ or US-20030008231-\$ or US-20030022101-\$ or US-20030152864-\$ or US-20020128336-\$ or US-20030157432-\$ or US-20020004569-\$ or US-20030157801-\$).did. or (WO-200290423-\$).did.)) </p>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/03/31 21:22
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